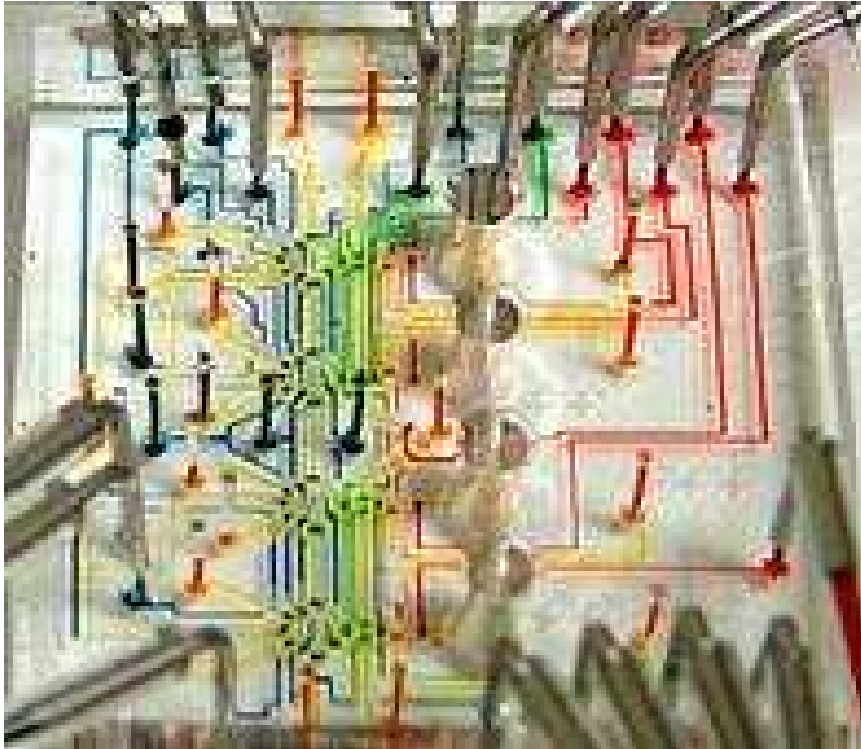




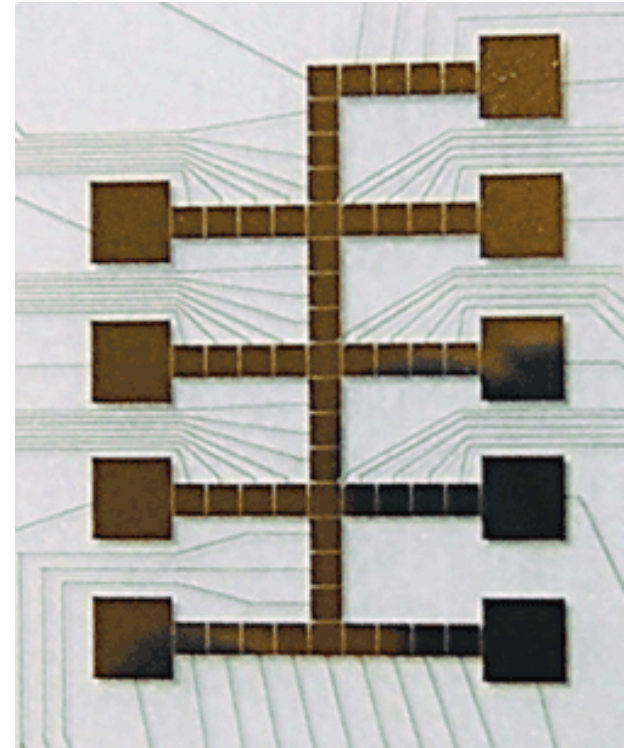
Developing a Digital Microfluidics Platform for Genetic Characterization of Pathogens

By: Eric Kittlaus and Marielle Remillard

Overview of Microfluidic Devices

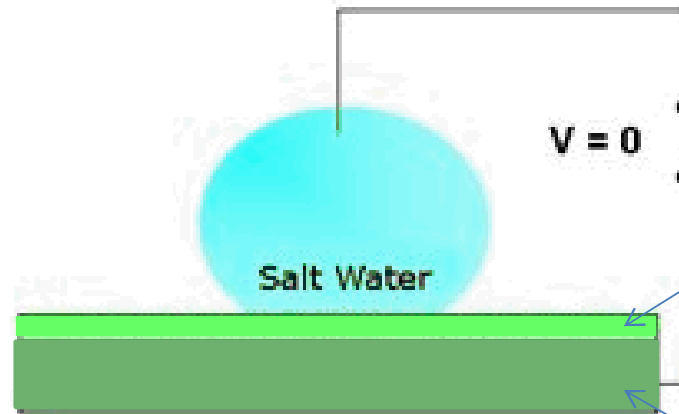


Continuous Flow Microfluidics



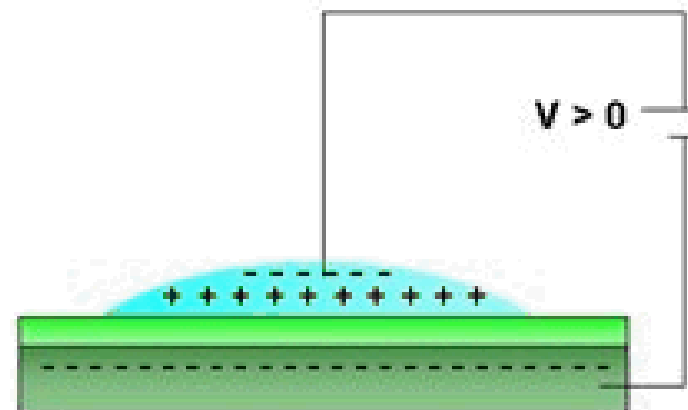
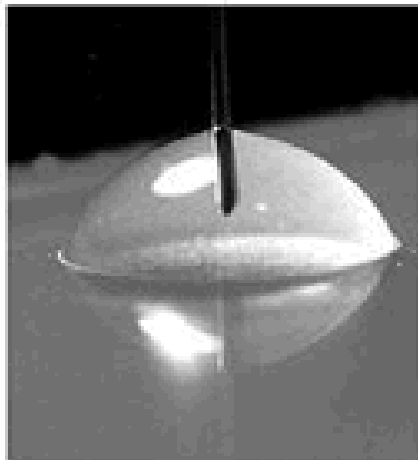
Digital Microfluidics

Basic Idea: Electrowetting

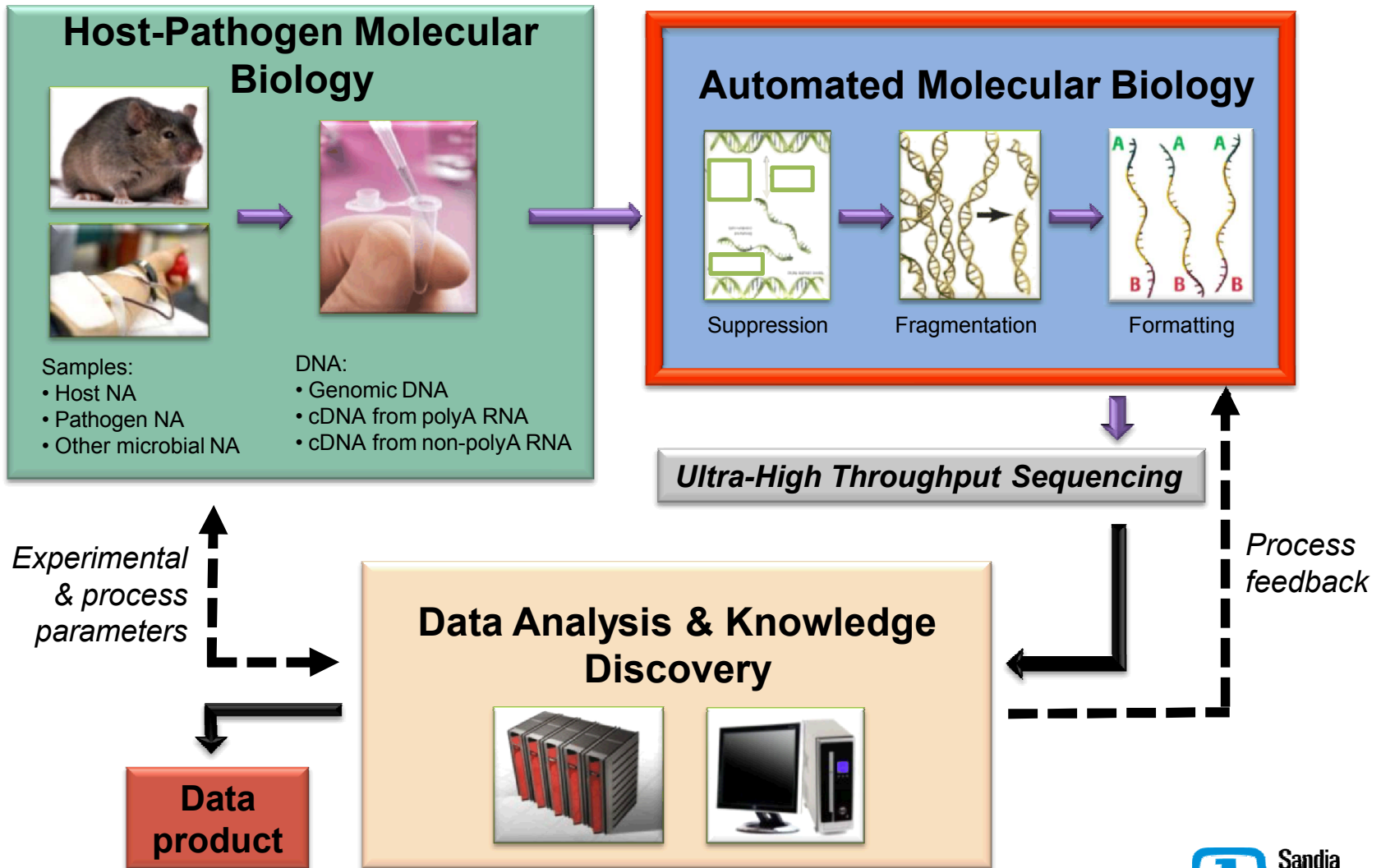


Dielectric Insulator
covered with a
Hydrophobic Material

Metal Electrode

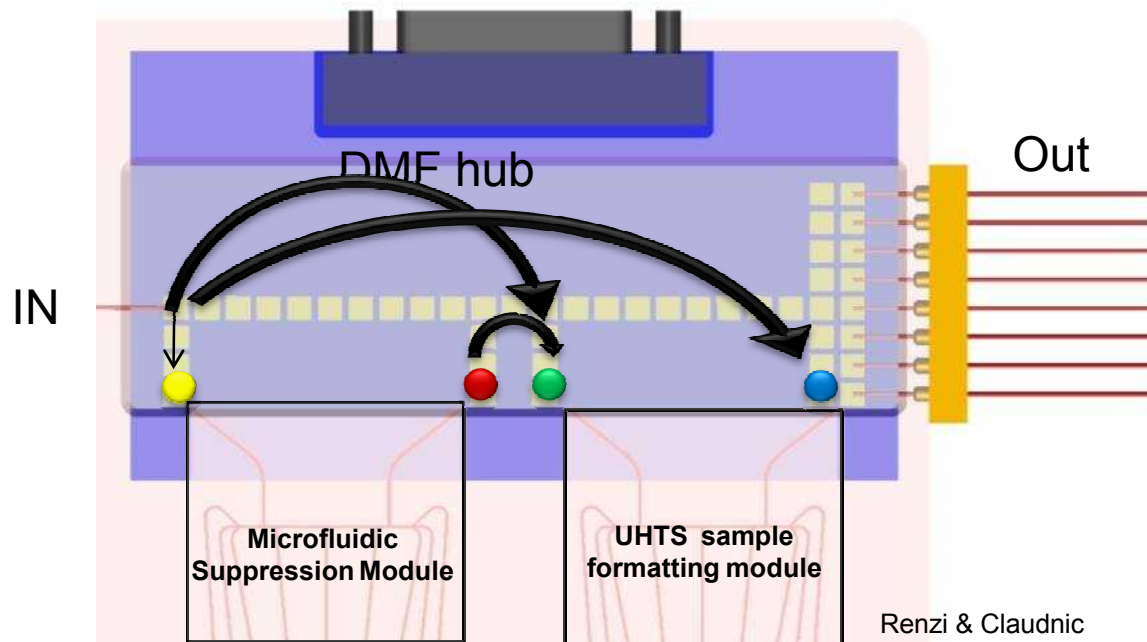


Background/RapTOR concept



Digital Microfluidic Array for Central Hub

- **Central hub architecture with surface-bound microdroplets**
 - Input and output of suppression and formatting modules controlled through automated DMF hub
- **Flexible approach**
 - allows the efficient transfer of small quantities of DNA sample with precise temporal and spatial control



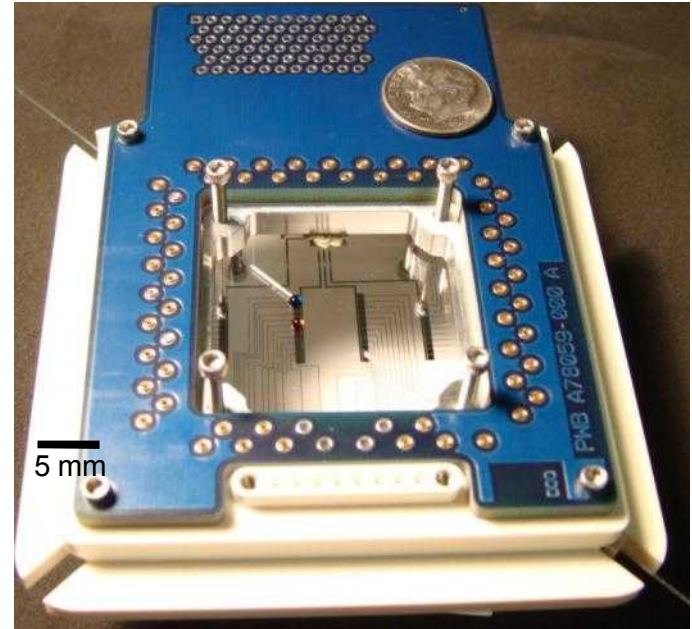
The DMF platform for manipulating of DNA samples

•Sandia manufacturing abilities

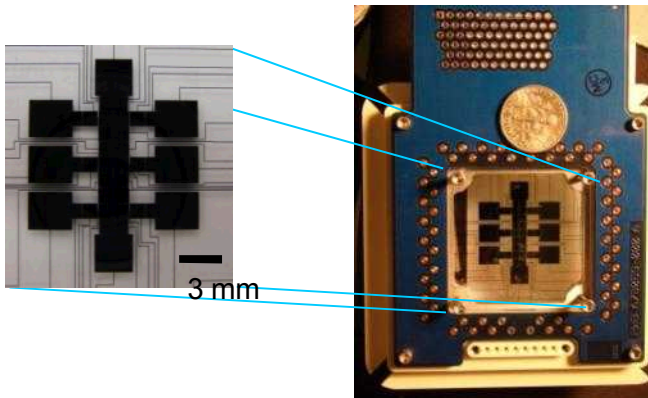
- Fabricate DMF housing and devices for prototyping and testing
- Programmable interface
- Automatic fluid handling and routing

• Demonstrated basic droplet operations (splitting, mixing, merging, incubation)

- 600 nL dispensing
- Precise actuation and mixing

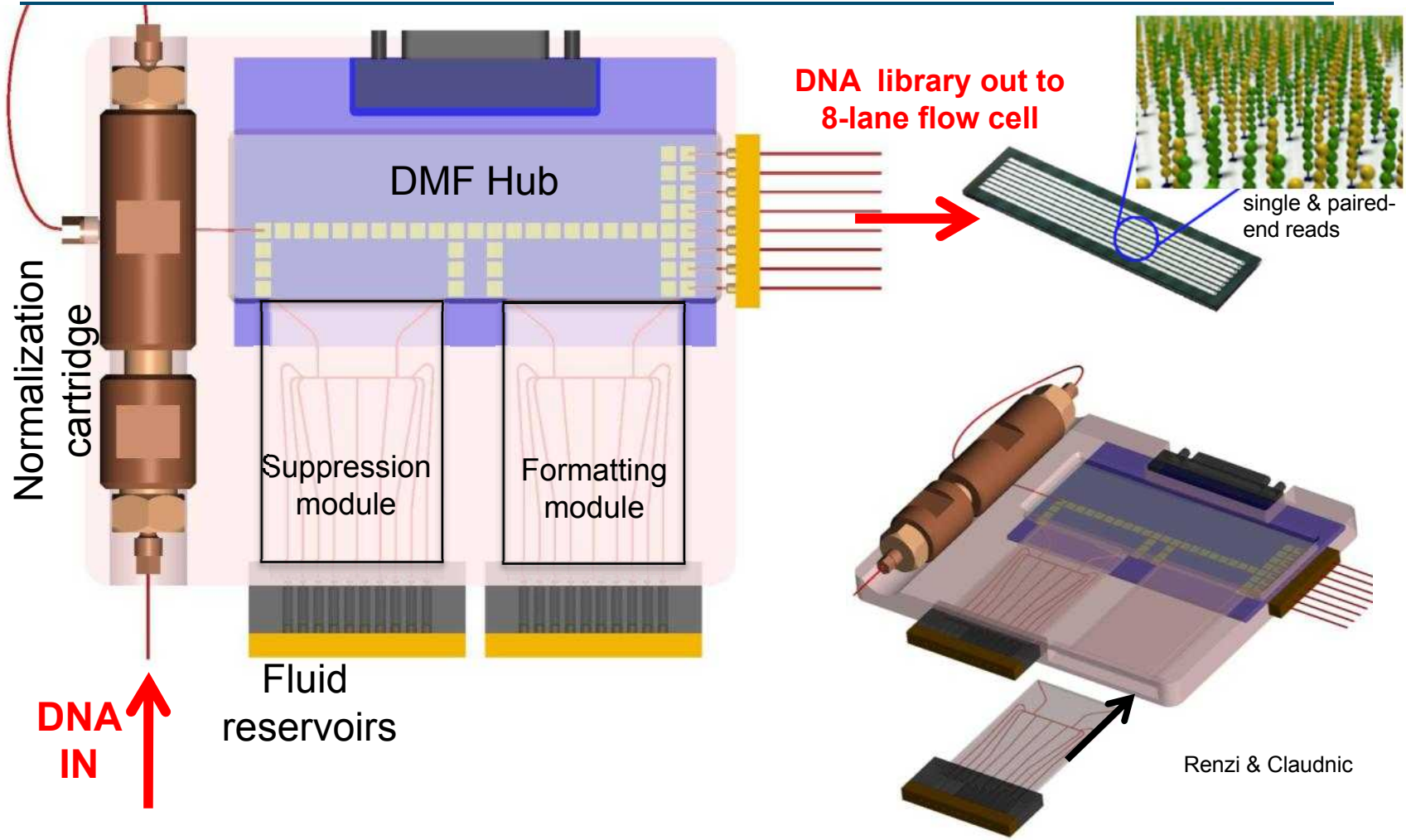


Renzi & Van De Vreugde





RapTOR platform for processing nucleic acids samples



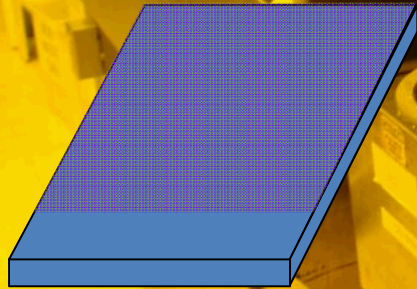
Clean Room Fabrication

1. Photoresist Coat
2. UV Exposure
3. Develop in Solution
4. Etch with HCl
5. Strip Photoresist
6. Dielectric Coating
7. Teflon AF Coating



2007 2 15

Clean Room Fabrication

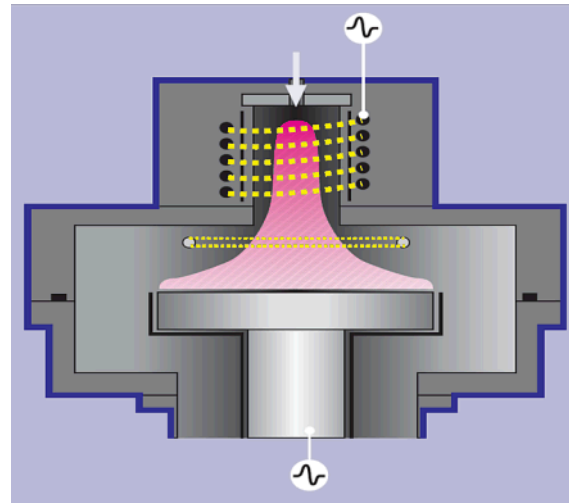
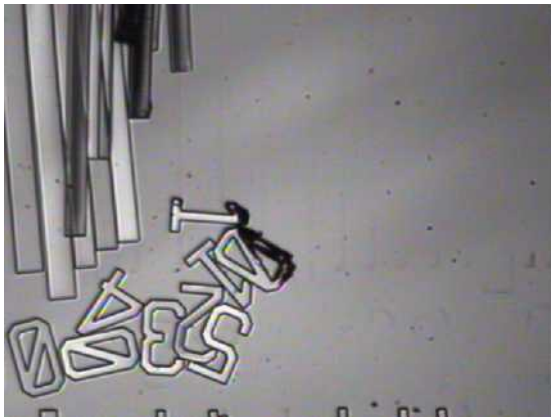
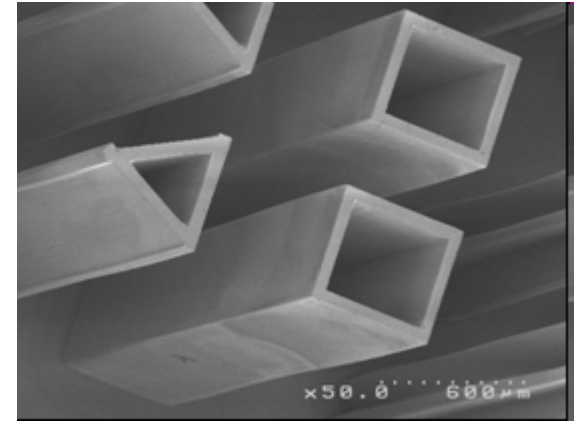


1. Dielectric Coating
2. Teflon AF Coating

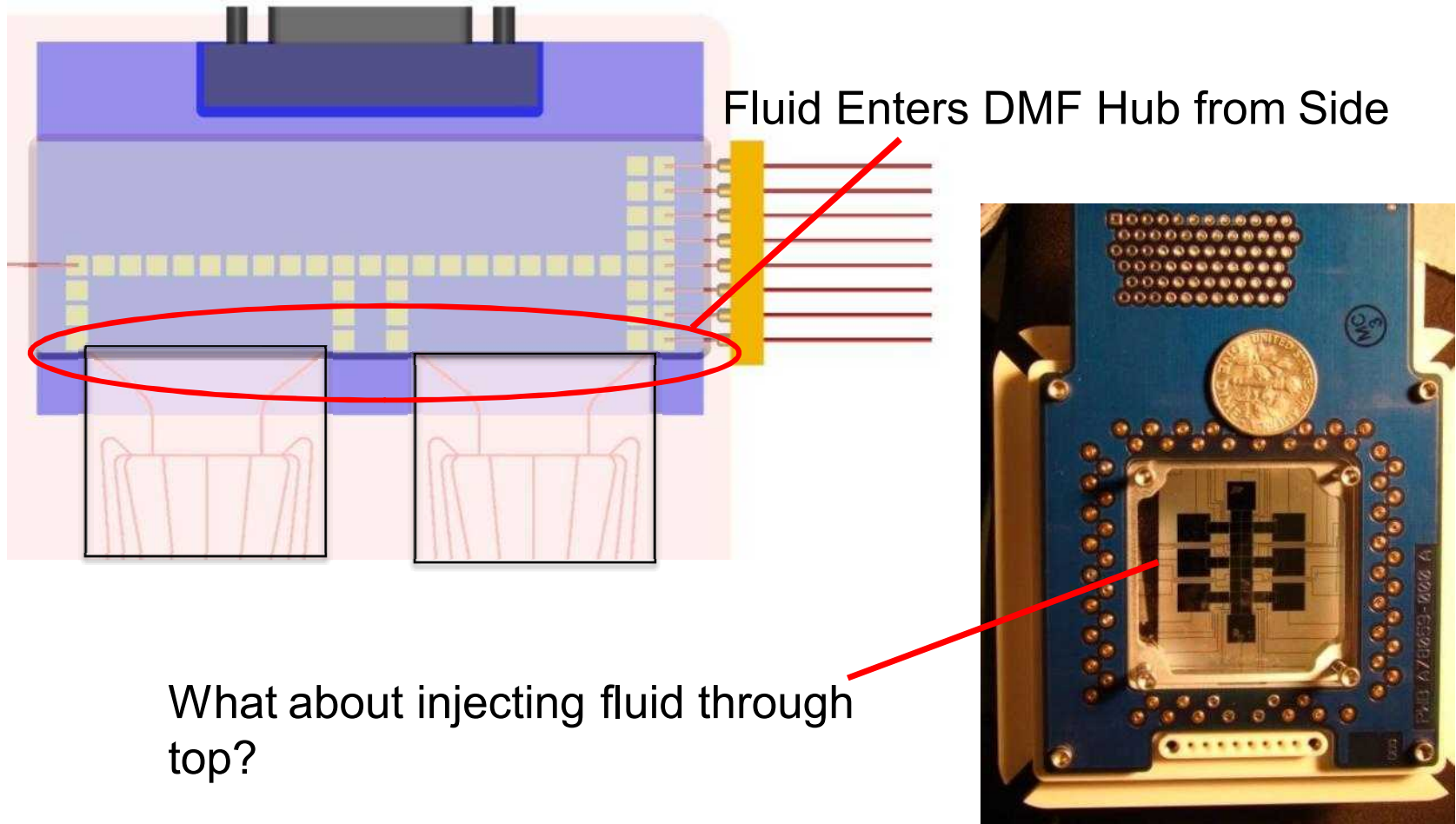
2007-2-15

Fabrication Modifications

- Exposure time
- Etching time
- Plasma Etching
- Dielectric (SU-8 vs. Parylene)



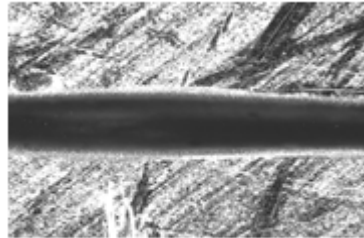
Mechanical Stage



Femtosecond Laser Machining

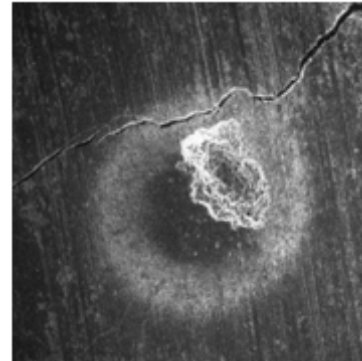


Conventional Laser

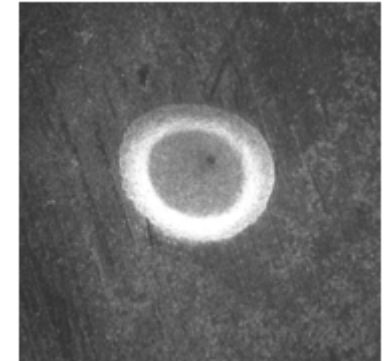


Femtosecond Laser

LNL



Conventional Laser



Femtosecond Laser

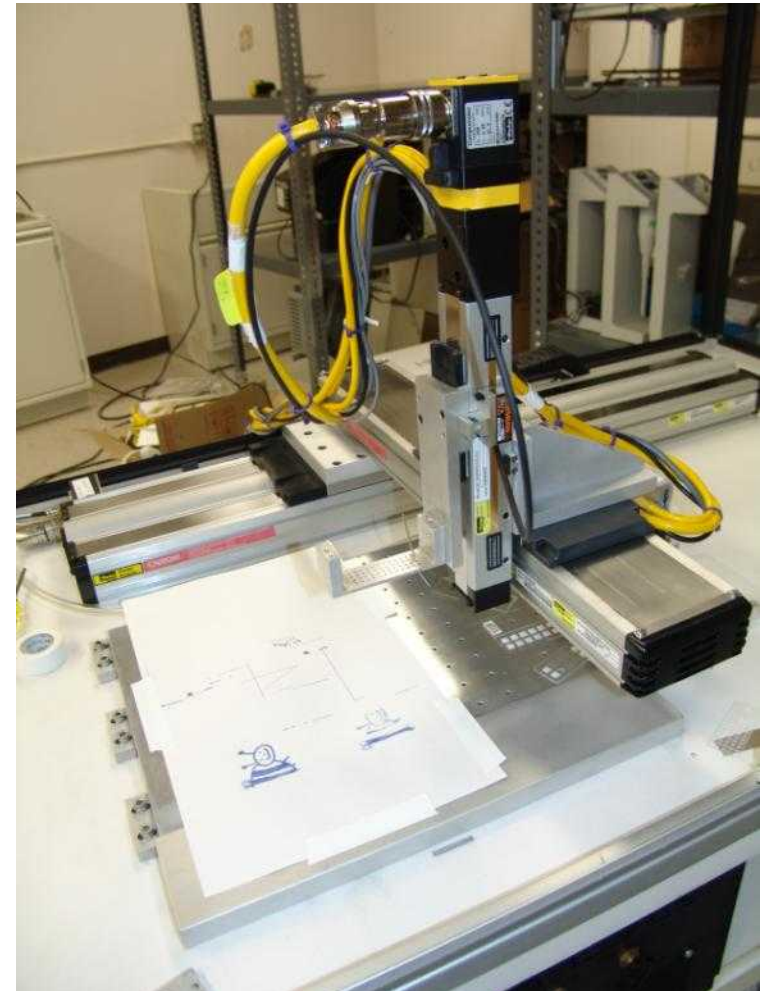
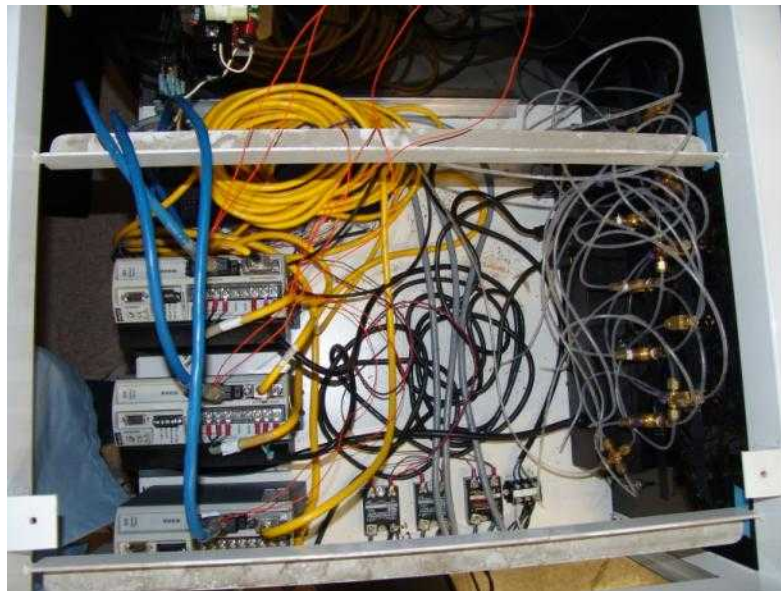
LNL

- Photons absorbed on femtosecond timescale
- Complete resolidification after $1\mu\text{s}$ elapsed
- Result Is cleaner machining
- No slag, cracking



Machining: Mechanical Stage

- Concept: used to move DMF platform for hole drilling
- <1 micron resolution





Mechanical Stage

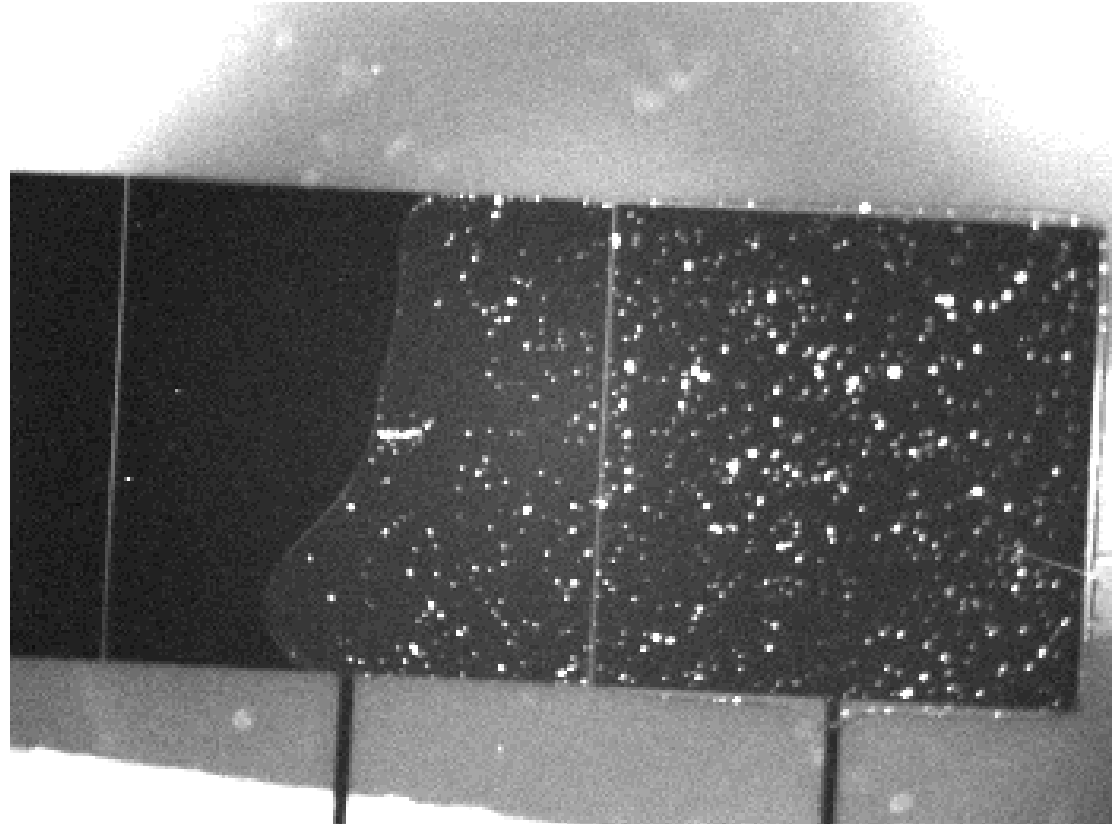


Mechanical Stage: Finished Product

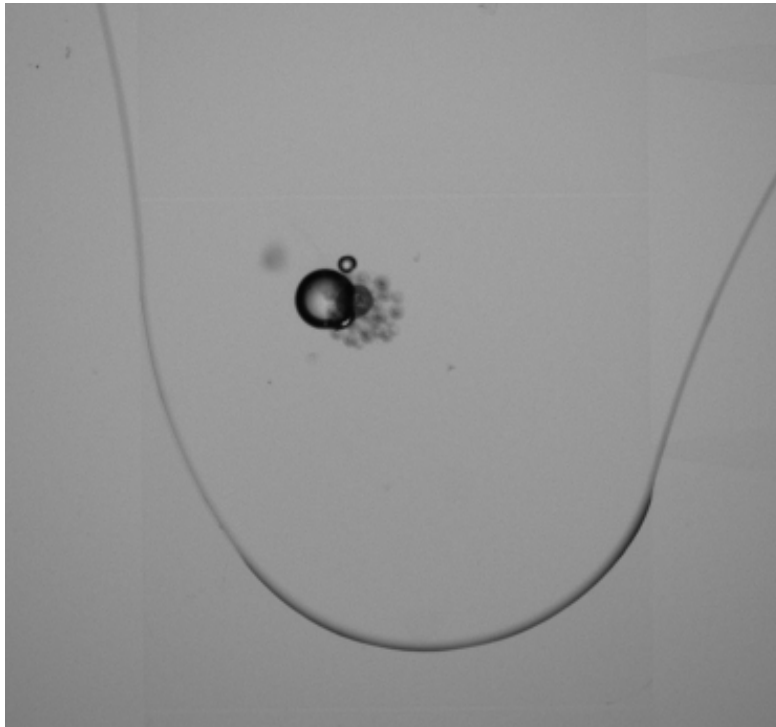


1st Attempt at Moving Cells

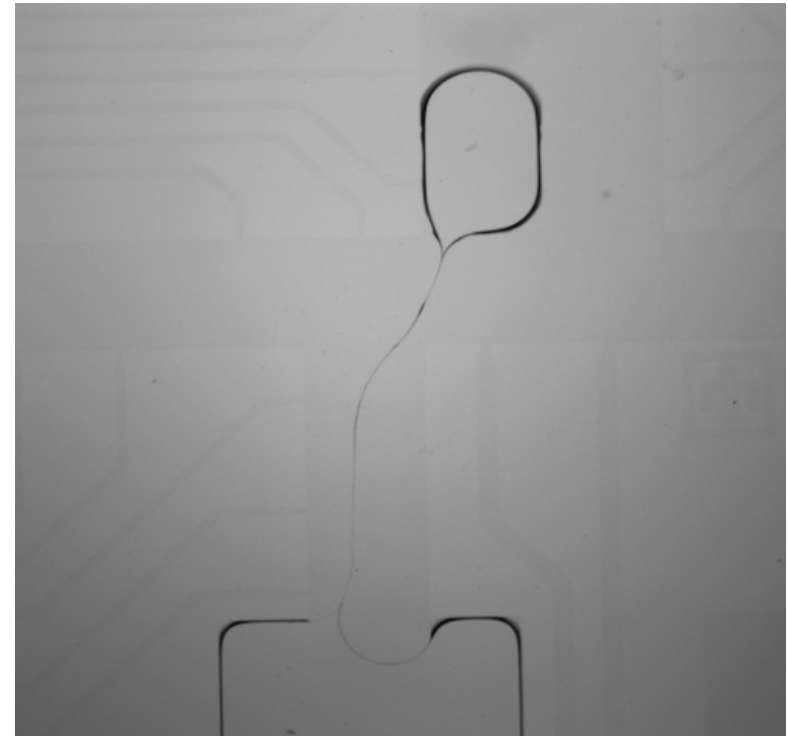
- Fluorescent P388D.1 Cells
- Chrome
- Parylene dielectric
- **HIGH VOLTAGE (160 Vrms)**



Challenges with PBS and F127

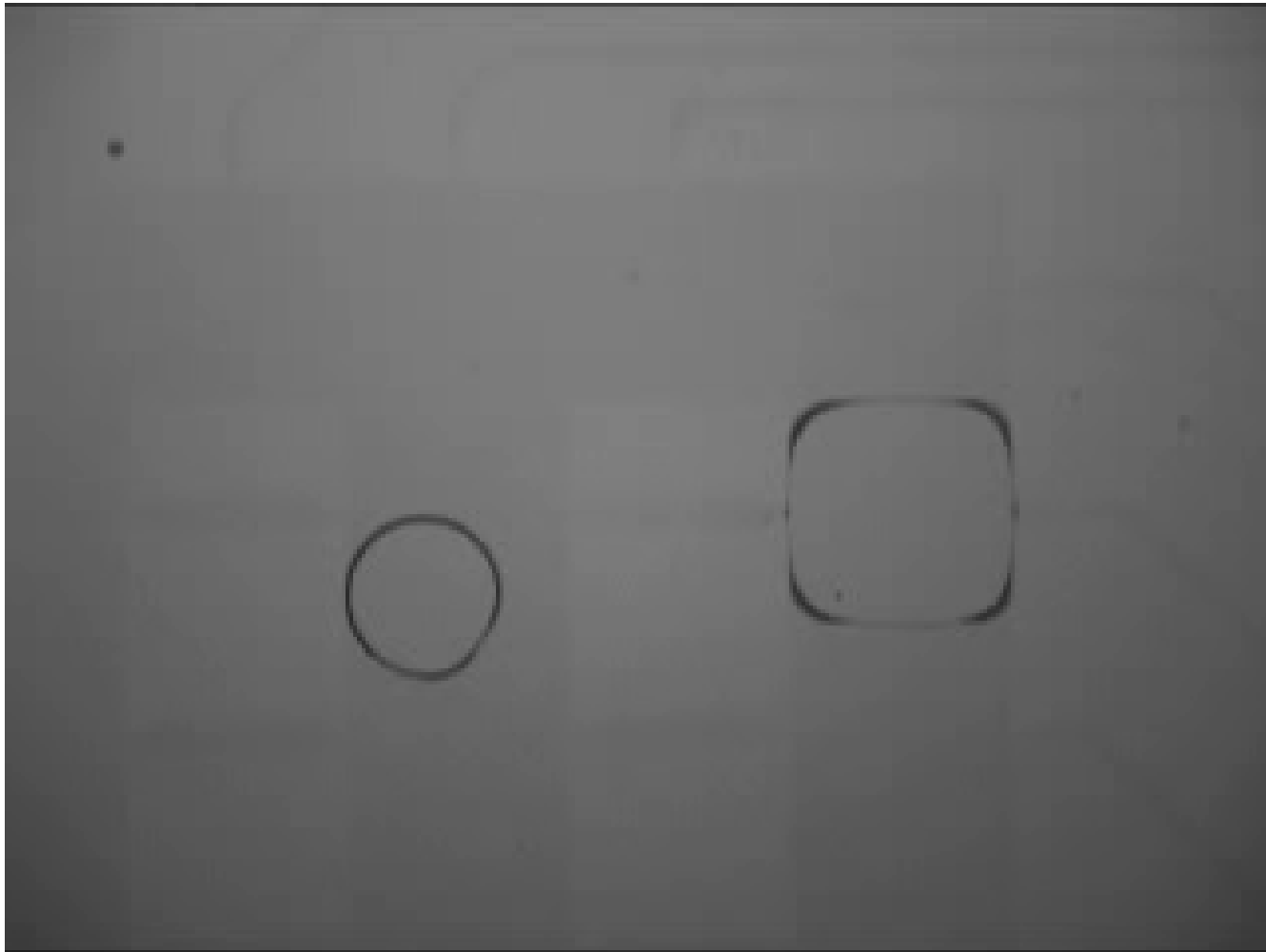


**1% Pluronic F127 in 1X PBS,
SU8 dielectric**



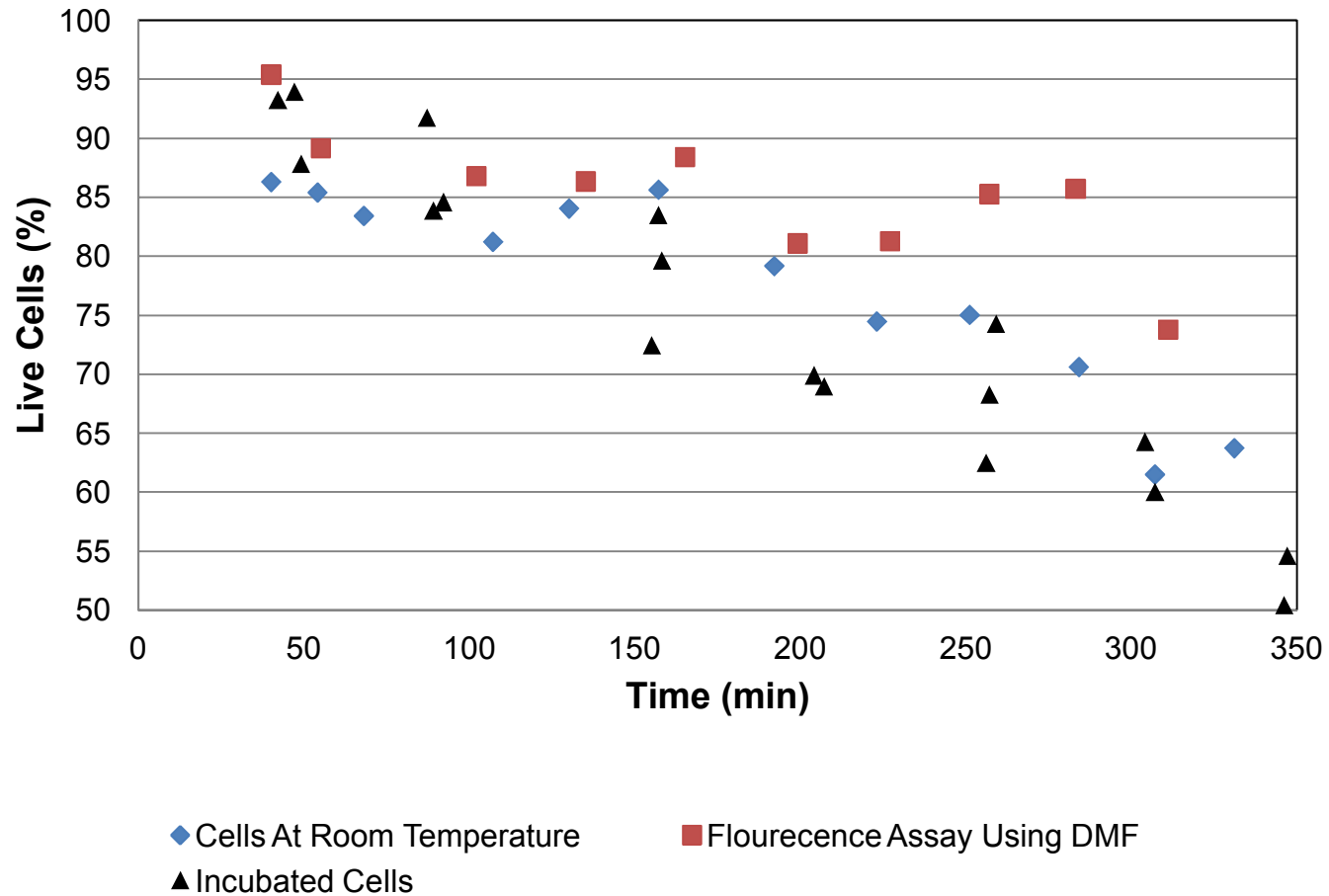
**2% Pluronic F127 in 1X PBS,
SU8 dielectric**

Live Dead Assay Using DMF





How long will the cells survive?



Acknowledgements



- Ken Patel
- Hanyoup Kim
- Mike Bartsch
- Genny Pezzola
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- Sandia National Labs

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Sources

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- Fusayo Saeki, Jean Baum, Hyejin Moon, Jeong-Yeol Yoon, Chang-Jin “CJ” Kim and Robin L. Garrell. “Electrowetting on Dielectrics (EWOD): Reducing Voltage Requirements for Microfluidics” <http://aq.arizona.edu/research/biosensors/acs01b.pdf>
- http://pubs.acs.org/cen/_img/87/i29/8729scon_microfluidic.gif